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國立臺灣大學113學年度轉學生招生考試試題

科目:材料科學導論

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※ 注意:請於試卷上「非選擇題作答區」標明題號並依序作答。

- I. Multiple choices (There may be more than one correct answer. Except for the last question, all others have 7 points each. One error costs you 4 points, until no more point is available with that particular problem)
- 1. Apple iPhone 15 Pro and iPhone 15 Pro Max use titanium as the material for their cases. About titanium, which of the following are correct?
 - (A) The primary crystal structure of commercially pure titanium at room temperature is body-centered cubic (BCC).
 - (B) Titanium is often alloyed with aluminum and vanadium to form Ti-6Al-4V, which has a dual-phase structure at equilibrium at room temperature.
 - (C) Titanium alloys are generally difficult to machine due to their low thermal conductivity and high chemical reactivity at elevated temperatures.
 - (D) The density of titanium is approximately 4.5 g/cm³, making it heavier than stainless steel but lighter than aluminum.
 - (E) Pure titanium is used extensively in high-temperature applications because it retains its strength at temperatures above 1000°C.
- 2. Which of the following can be considered a method used to enhance the toughness of ceramic materials?
 - (A) Incorporation of whiskers or fibers
 - (B) Grain size refinement
 - (C) Doping with rare earth elements
 - (D) Increasing the brittleness of the ceramic
 - (E) Introduction of porosity
- 3. Which of the following statements about polymers is correct?
 - (A) Thermosetting polymers can be melted and reshaped multiple times.
 - (B) Polymers with high crystallinity generally have lower density and higher solubility in solvents.
 - (C) Cross-linking in polymers increases their flexibility and reduces their melting temperature.
 - (D) Glass transition temperature (T_9) is the temperature above which a polymer becomes brittle.

(E) This is a repeating unit of polypropylene.

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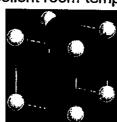
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4. TSMC (Taiwan Semiconductor Manufacturing Company) is recently reported the 8th largest company in the world. In the context of the semiconductor industry, which of the following statements are true?

- (A) Moore's Law predicts that the number of transistors on a chip doubles approximately every 12 months.
- (B) The process of doping involves introducing impurities into a semiconductor to modify its electrical properties.
- (C) Photolithography is a key technique used in semiconductor manufacturing for patterning the intricate circuits on silicon wafers.
- (D) Silicon is the only material used for making semiconductor devices.
- (E) FinFET (Fin Field-Effect Transistor) technology is used to overcome short-channel effects in modern transistors.
- 5. About an intermetallic compound Ni₃AI...
 - (A) It has a face-centered cubic (FCC) crystal structure.
 - (B) It is known for its excellent high-temperature strength and oxidation resistance, making it suitable for high-temperature applications.
 - (C) It is widely used for improvement of magnetic properties, such as permanent magnets.
 - (D) It is most well-known for its excellent room-temperature ductility.



- (E) The unit cell may look like this:
- 6. Which of the following statements about the thermal properties of materials are correct?
 - (A) At 0 K, the entropy of all materials is 0.
 - (B) The specific heat capacity of a material is independent of temperature.
 - (C) Thermal expansion refers to the change in a material's volume with a change in temperature.
 - (D) The coefficient of thermal expansion quantifies the fractional change in length per degree change in temperature.
 - (E) Heat capacity is defined as the amount of heat required to raise the temperature of by one degree Celsius.
- 7. Which of the following statements about diffusion in solids are true?

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(A) Diffusion in metals primarily occurs through vacancy and interstitial mechanisms.

- (B) The diffusion coefficient increases with decreasing temperature.
- (C) In a substitutional alloy, atoms can only diffuse through the interstitial mechanism.
- (D) Fick's first law of diffusion states that the flux of atoms is proportional to the concentration gradient.
- (E) The activation energy for diffusion is typically lower in crystalline solids compared to amorphous solids.
- 8. Which of the following statements about electronic structures in materials are correct?
 - (A) The band gap of a semiconductor decreases with increasing temperature.
 - (B) In metals, the Fermi level lies within the conduction band at absolute zero temperature.
 - (C) Doping a semiconductor with donor impurities shifts the Fermi level closer to the conduction band.
 - (D) The density of states in a material describes the number of electronic states at each energy level that are available to be occupied.
 - (E) In an insulator, the valence band is completely empty at absolute zero temperature.
- 9. Which of the following phenomena related to light are primarily influenced by the material's electronic structure and band gap properties?
 - (A) Photoluminescence
 - (B) Total internal reflection
 - (C) Photoelectric effect
 - (D) Optical absorption
 - (E) Diffraction
- 10. Which of the following statements about the hardenability of steels are true?
 - (A) Hardenability can be influenced by the carbon content in steel.
 - (B) The Jominy end-quench test is a standard method used to measure the hardenability of a steel sample.
 - (C) Hardenability determines the maximum hardness that can be achieved in a steel alloy.
 - (D) Alloying elements such as chromium, molybdenum, and manganese

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increase the hardenability of steel.

- (E) Hardenability is the ability of a steel to be hardened throughout its entire thickness.
- 11. In the context of pitting corrosion, which of the following factors are most likely to initiate and propagate pitting corrosion on a stainless steel surface?
 - (A) Presence of chloride ions in the environment.
 - (B) High pH (alkaline) environment.
 - (C) Surface passivation with a protective oxide layer.
 - (D) Localized breakdown of the protective oxide film.
 - (E) Uniform exposure to oxygenated water.
- 12. At the eutectic composition and eutectic temperature, which of the following statements are correct?
 - (A) The eutectic reaction is described by Liquid $\rightarrow \alpha + \beta$
 - (B) At the eutectic temperature, the liquid phase transforms into two solid phases simultaneously.
 - (C) Eutectic transformation is a type of congruent transformation.
 - (D) The eutectic point is a unique composition at which the eutectic reaction occurs.
 - (E) The eutectic structure typically consists of alternating layers or lamellae of the two solid phases.
 - (F) The eutectic reaction results in the formation of a single supersaturated solid phase from the liquid phase.
- 13. A high degree of substitutional solid solubility of one atom type in another is possible when the Hume-Rothery rules are obeyed. The rules describe:
 - (A) The crystal structures for metals of both atom types must be the same.
 - (B) Atomic sizes of two elements must not differ by more than 15%.
 - (C) Elements should form compounds with each other.
 - (D) High difference in electronegativity is a requirement.
 - (E) Elements should have the same valence electrons.
- 14. Which of the following statements are true regarding the optical properties of materials?
 - (A) The refractive index of a material is always greater than 0.95.
 - (B) Materials with a high refractive index always exhibit strong absorption of light.

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- (C) Photoluminescence is the emission of light from a material after it absorbs photons.
- (D) Transparent materials have a high absorption coefficient.
- (E) The band gap of a semiconductor determines the wavelengths of light it can absorb.
- (F) Metals typically exhibit high reflectivity due to free electrons on their surface.
- (G) Metamaterials can be engineered to have unusual optical properties, excluding a negative refractive index.